

INFORMATION DISCLOSURE CITATION
(Use several sheets if necessary)

ATTY DOCKET NO.
WLJ.070D

SERIAL NO.
NEW

John MacNeil et al.

10/618636

FILING
July 15, 2003

GROUP
2813
~~To Be Assigned~~

U.S. PATENT DOCUMENTS

| EXAMINER INITIAL | | DOCUMENT NUMBER | DATE | NAME | CLASS | SUBCLASS | FILING DATE IF APPROPRIATE |
|---------------------|---|-----------------|------------|-----------------|-------|----------|-------------------------------|
| TS | A | 5,514,604 | 05/07/1996 | BROWN | | | |
| TS | B | 5,244,698 | 09/14/1993 | ISHIHARA et al. | | | |
| TS | C | 4,647,472 | 03/03/1987 | HIRAKI et al. | | | |
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FOREIGN PATENT DOCUMENTS

| | | DOCUMENT NUMBER | DATE | COUNTRY | CLASS | SUBCLASS | TRANSLATION | |
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| | | | | | | | YES | NO |
| TS | F | EP 1 059 664 A2 | 12/13/2000 | EPO | | | | |
| TS | G | WO 99/56310 | 04/11/1999 | PCT | | | | |
| TS | H | WO 99/33102 | 07/01/1999 | PCT | | | | |
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OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

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| TS | K | "Dual-Damascene Challenges Dielectric Etch", Semiconductor International, August 1999, pages 69-72. | | | | | |
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EXAMINER

DATE CONSIDERED

1/24/05

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

